

## REMARKS

By this response claims 20 and 21 have been amended and claims 27-31 have been added. Claims 17-21 and 23-31 are pending. Claims 17-20 and 24-26 have been deemed allowable.

The amendment to claim 20 does not adversely affect the allowability of the claim, as it depends from an allowed claim and merely changes the dependency of the claim.

### Rejections under 35 USC §103(a)

Claims 21 and 23 have been rejected under 35 USC §103(a) over Cho, et al. (US 6,781,183) and prior art FIG. 8 of the present application.

Claim 21 as amended overcomes the rejection under 35 USC §103(a). The combination of Cho, et al. and present FIG. 8 does not teach or suggest at least the added recitation that the dielectric layer interposed between two adjacent receptacles with an inhibitor layer contacting the dielectric layer. Thus claim 21, and rejected claim 23 which depends therefrom, are believed to be in condition for allowance

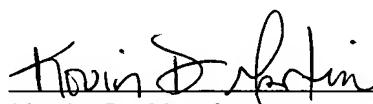
### Newly Added Claims

New claims 27-31 are believed to be allowable over the cited art. Claim 27 is allowable at least because it depends from an allowed base claim. Claim 28 is analogous to allowed claim 17, and is believed to be similarly allowable. Claims 29-31 are allowable at least because they depend from an allowable base claim.

### Conclusion

It is submitted that all remaining claims are in condition for allowance. If there are any matters which may be resolved or clarified through a telephone call, the Examiner is cordially invited to contact the undersigned. This is believed to be a complete response to the office action of December 5, 2005.

Respectfully submitted,

  
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